

Power Devices an Enabling Technology for Reliable and Efficient Power Converters -Technology Trends and Challenges-

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Role of Power Electronics for Energy Efficiency:

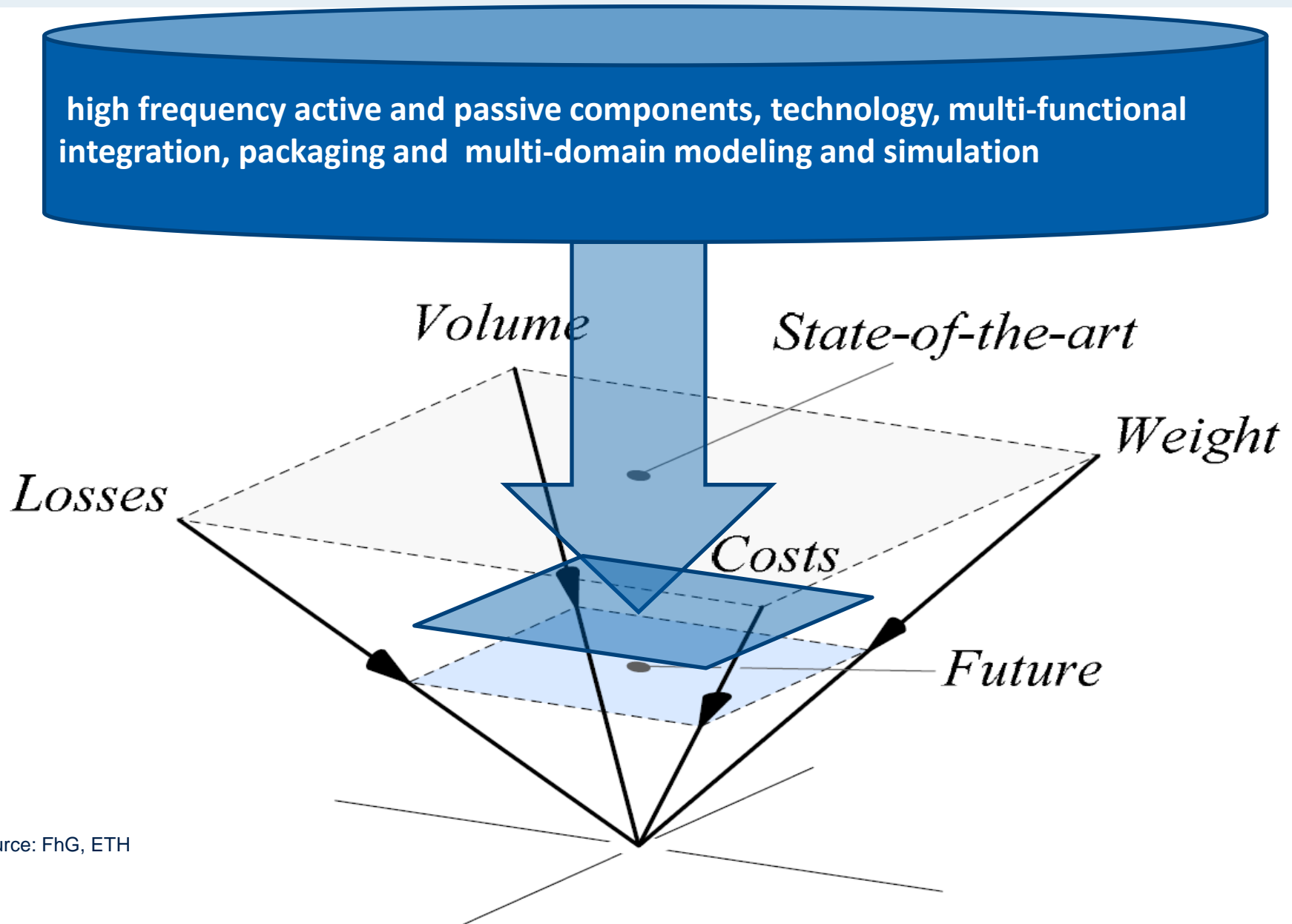
- Precise and High Efficient Control of Flow of el.Energy
- Ultra High Power Density Systems
- Elevated Operating Temperature
- System integration (μ E & PE & passive devices & thermal management)
- Highest Reliability and Ruggedness in the whole Energy Supply



Outline

- Introduction
- General Development Trends of Power Devices
- High Power Devices
 - => Chip Development
 - => Ruggedness & Reliability
 - => Development Trend
- Fast Switching Devices
 - => SJ-Technologies
 - => SiC-Devices
 - => GaN-Devices
 - => Challenges in Application
- Summary

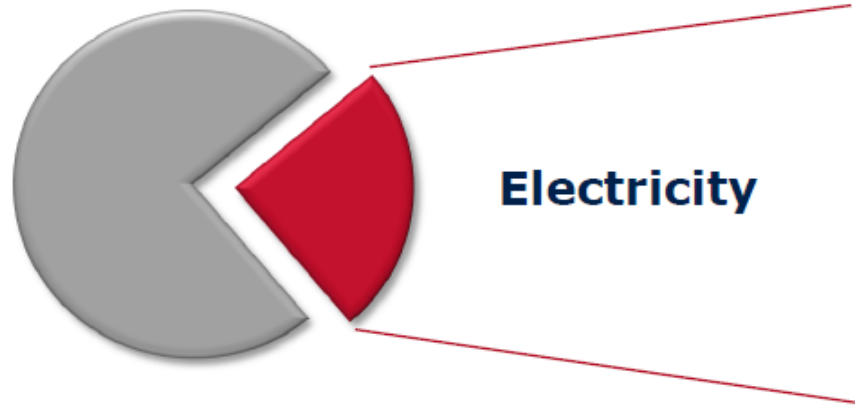
Multi-Technology-Integration



Good News is that $\sim 1/3$ of the Global Energy is Used as Electricity

While debate continues over the environmental impact of different means of electricity production, its final form is relatively clean & it is one of the easiest means of transporting energy over long distances!

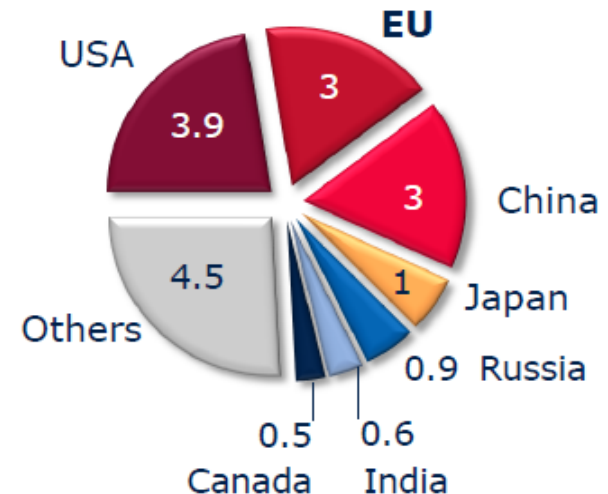
Global energy consumption 2008



$\sim 1/3$ of global energy consumption is electricity

Global electricity consumption 2008

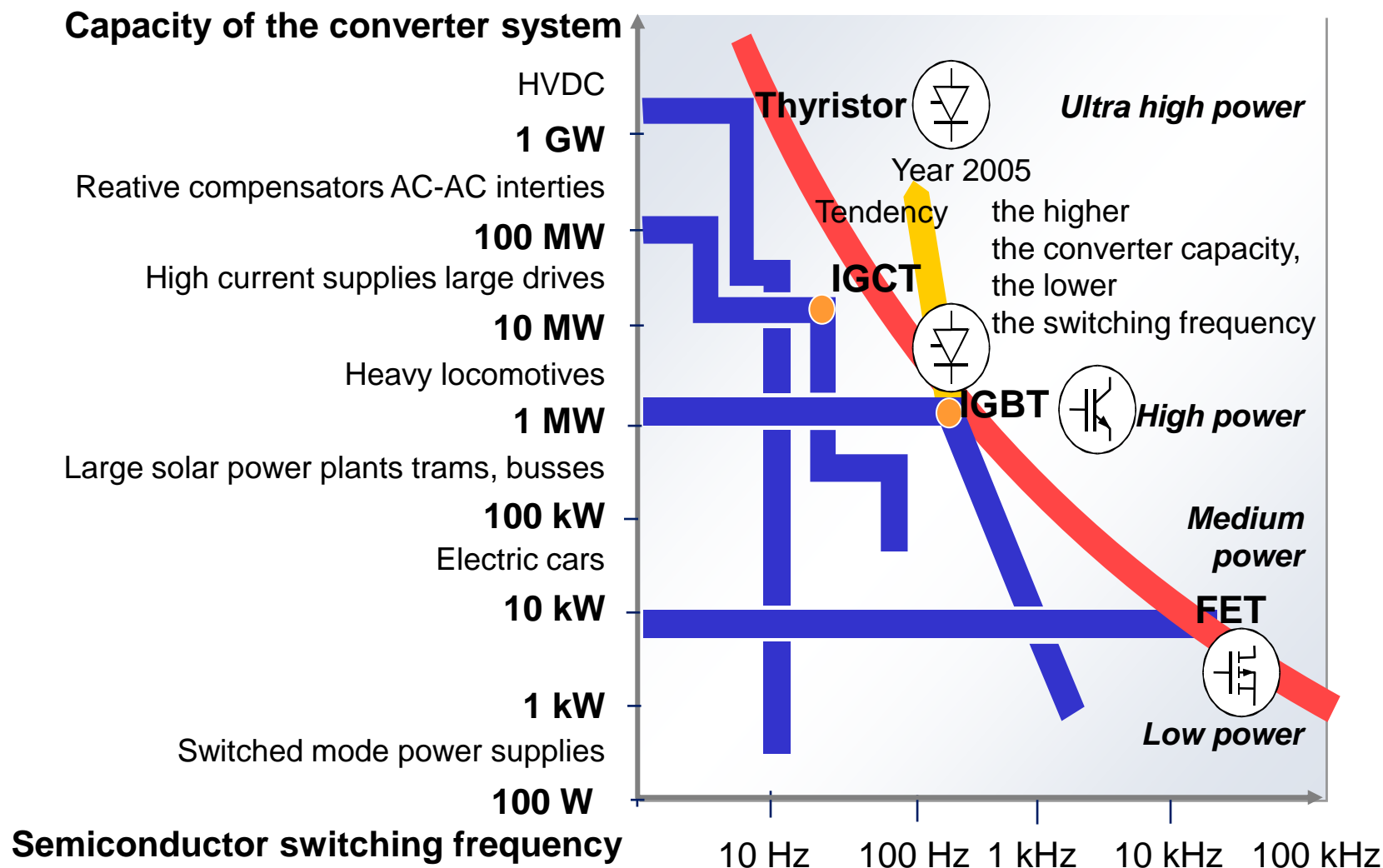
17.4 million GWh



USA, the EU and China are the largest consumers of electricity

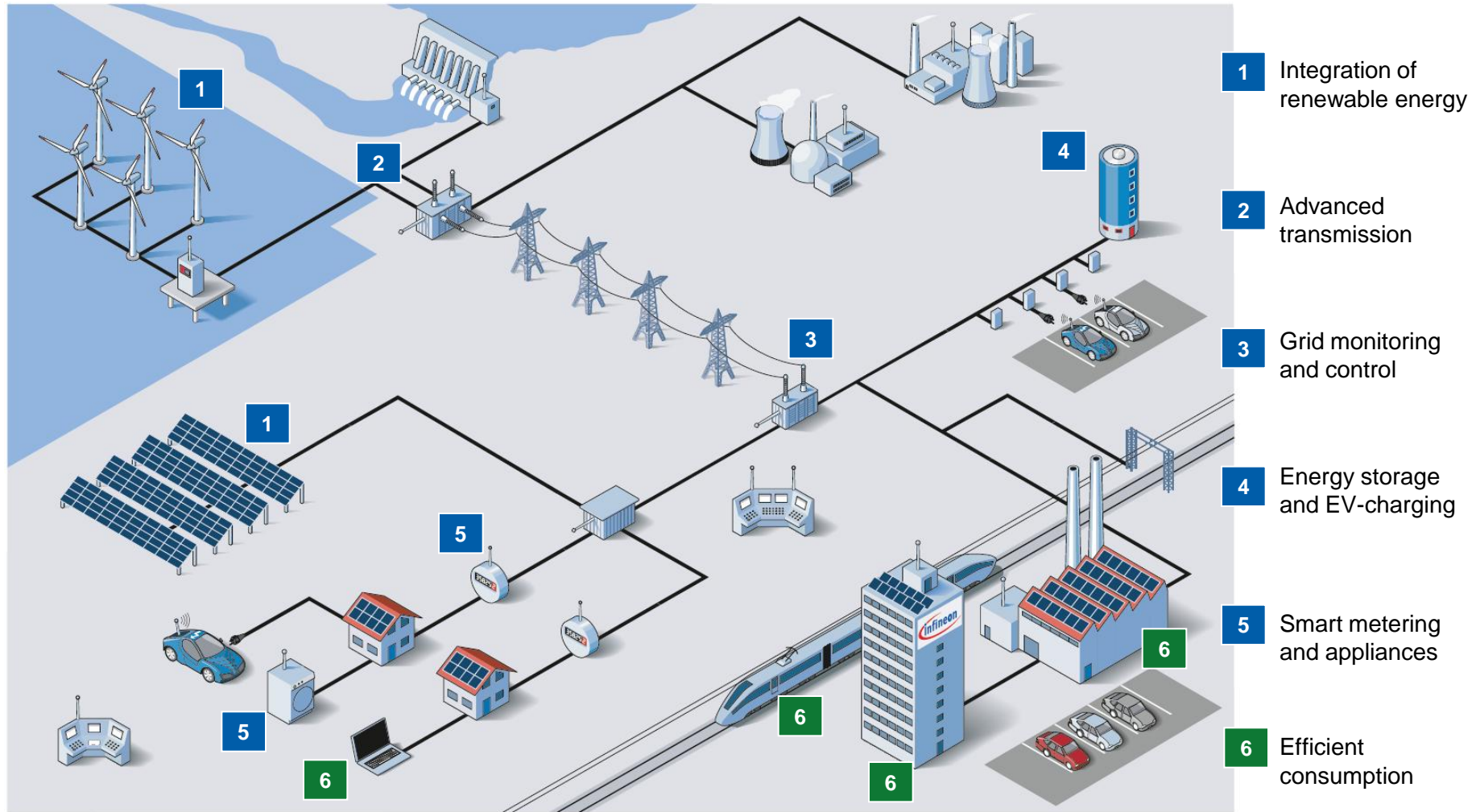
Sources: BP World Energy report; Energy Information Administration (EIA) – International Energy Statistics, 2010
EU includes all 27 member states of the EU (http://europa.eu/abc/european_countries/index_en.htm)

Application for Power Semiconductor Components



Source: IPEC 2000

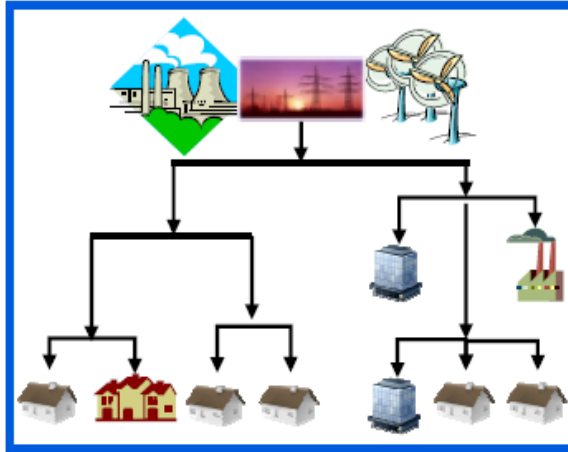
Smart Grids: advanced power control, intelligence and communications



Evolution of grid design

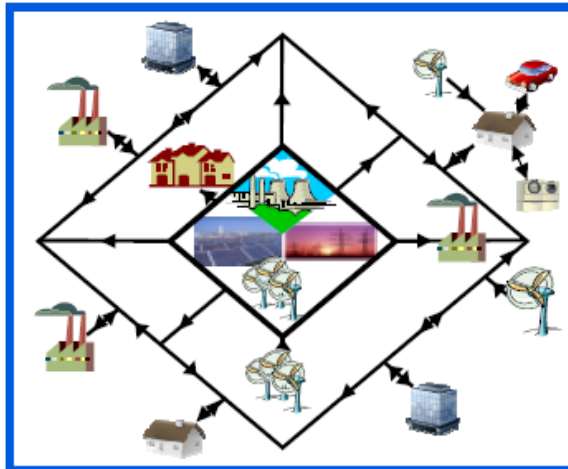
From traditional to future grids

traditional grids



- Centralized power generation
- One-directional power flow
- Generation follows load
- Operation based on historical experience
- Limited grid accessibility for new producers

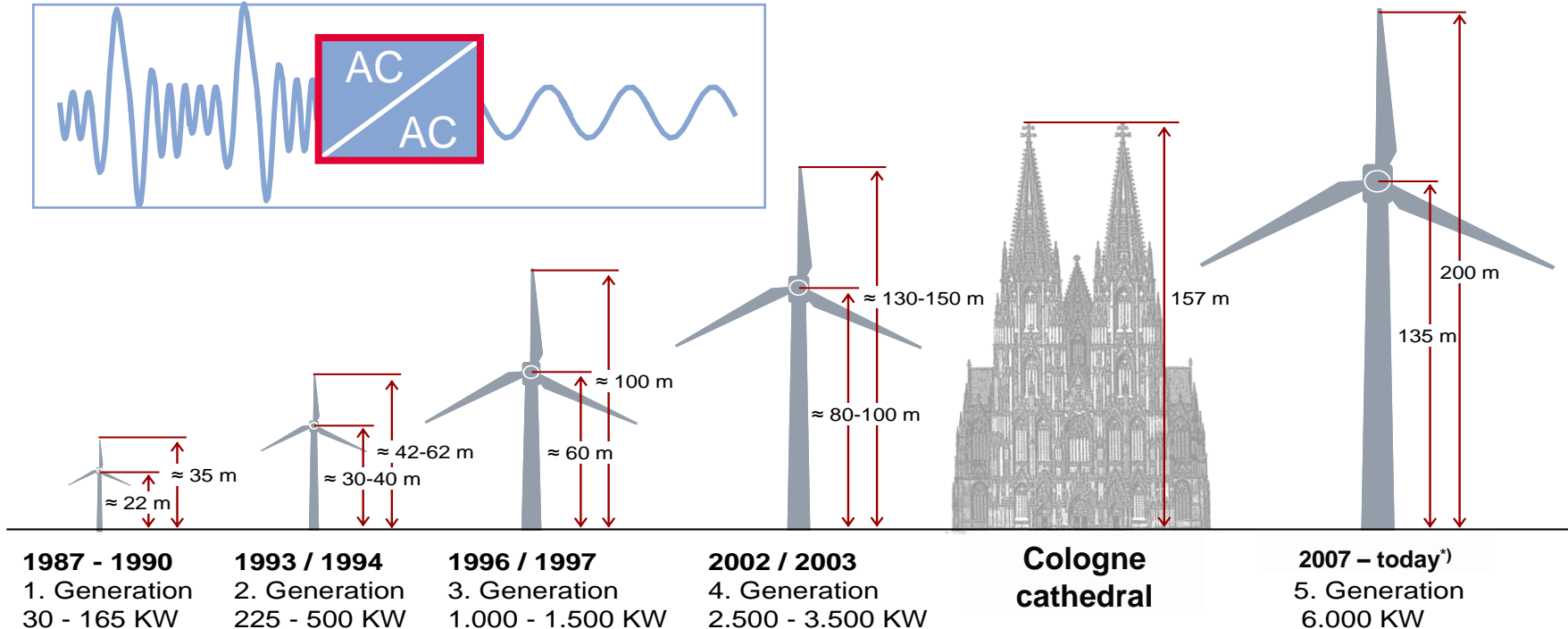
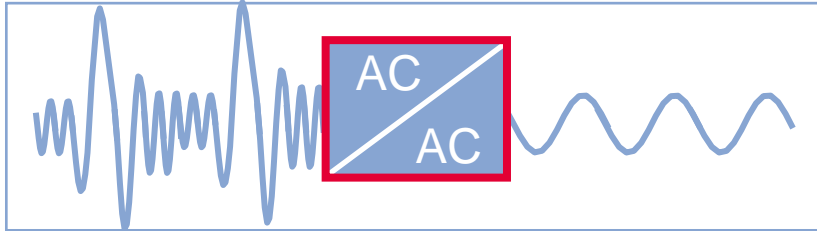
future grids



- Centralized and distributed power generation
- Intermittent renewable power generation
- Consumers become also producers
- Multi-directional power flow
- Load adapted to production
- Operation based more on real-time data

Source: ABB

As consciousness on renewable energy grows, so do the windmills & their output power!



BARD Offshore 1 (Germany's first off-shore wind park)

Location: 90 km northwest of Borkum, North Sea, Germany

Key data:

- 80 wind turbines of 5 MW each
- 400 MW total power generation
- completion expected end of CY 2010

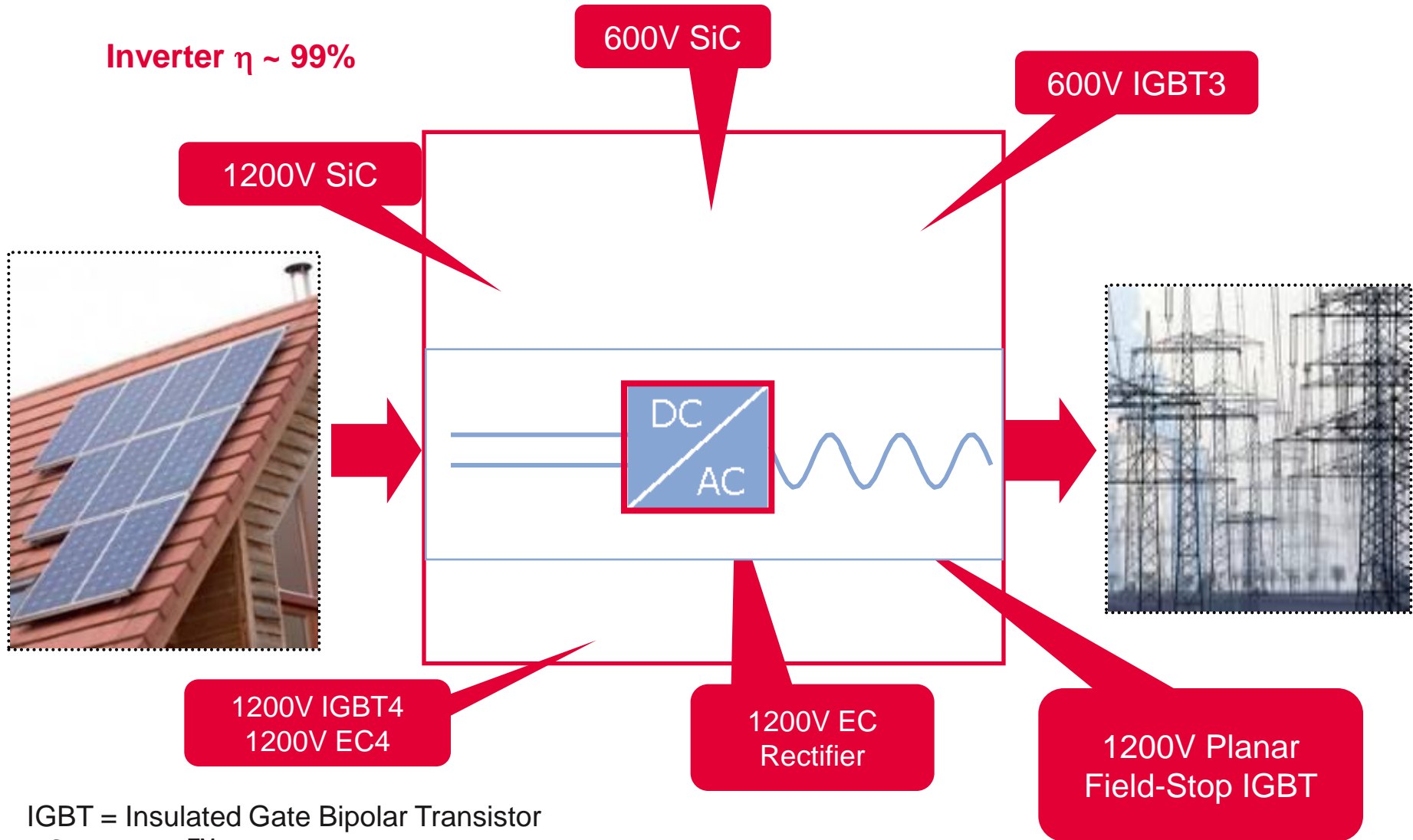
Components: Power module IHM 1700V



*) Source: Siemens Renewable Energy Division, 2009

Six technologies based on Silicon Carbide and Silicon, enable excellent energy conversion

Inverter $\eta \sim 99\%$



IGBT = Insulated Gate Bipolar Transistor
EC = Emcon™ Diode
SiC = Silicon Carbide component

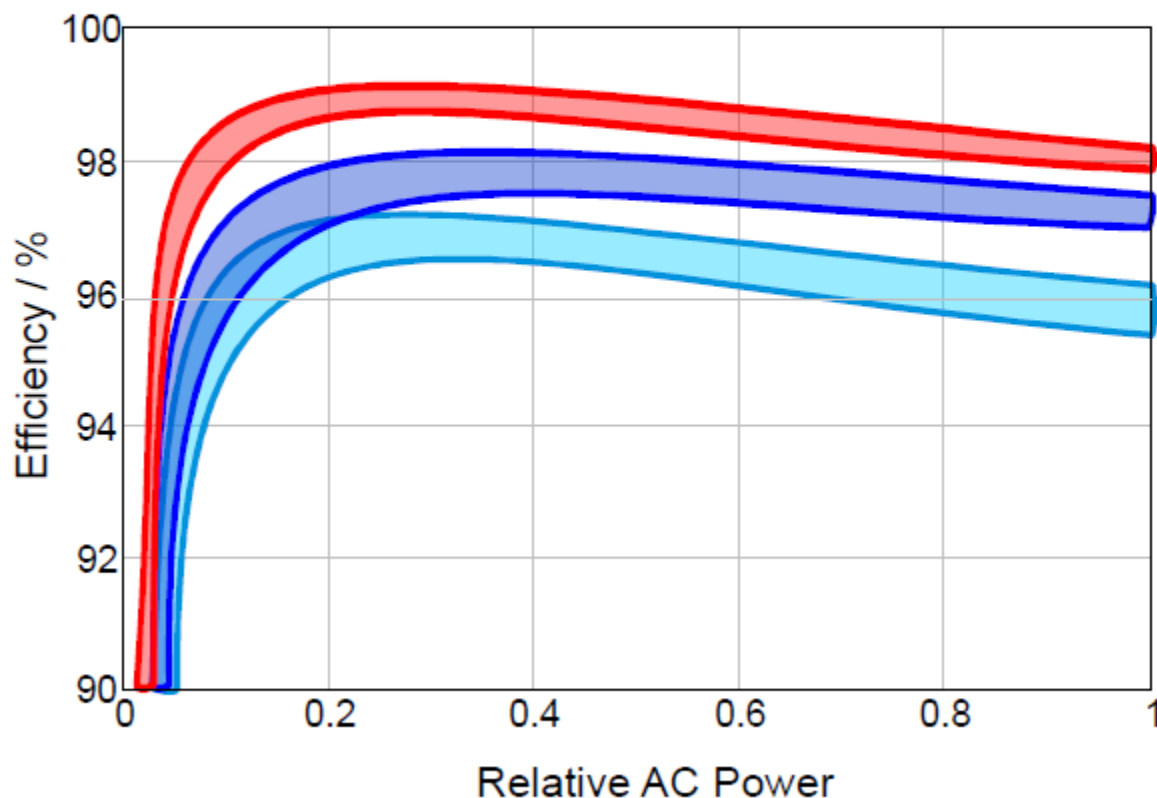
PV-Inverter Efficiency

Efficiency of transformerless PV inverters (5 kW, 16 kHz)

**SiC transistors,
three level topologies,
HERIC, H5, 3~NPC**

**IGBTs,
three level topologies,
HERIC, H5, 3~NPC
or
SiC-transistors,
two level topologies,
H4, B6**

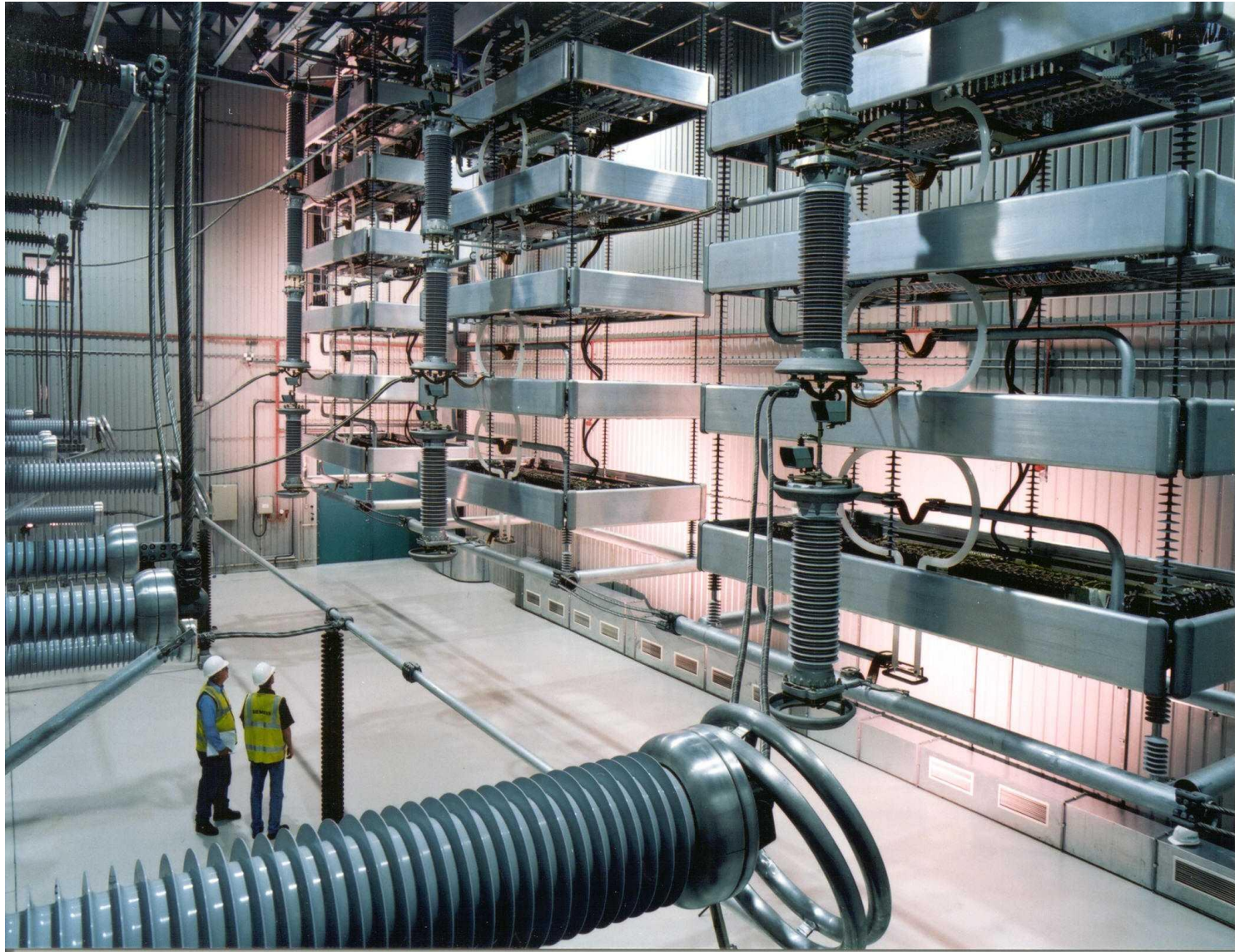
**IGBTs,
two level topologies,
H4, B6**



Valve Hall Moyle (2 x 250 MW HVDC Station)

fully equipped with light-triggered, BOD protected thyristors

2 converter stations (1 in Scotland, 1 in Northern Island) connected by sea cable



Semiconductors Play an Important Role in the Whole Electrical Energy Supply Chain

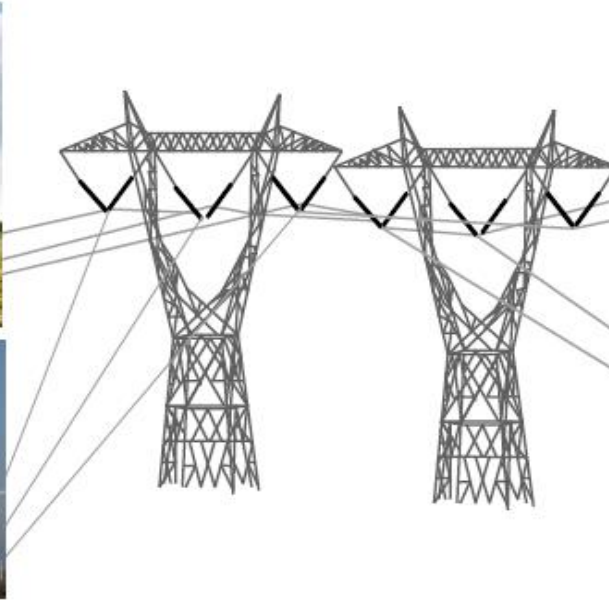


Energy supply chain

Energy generation



Energy distribution



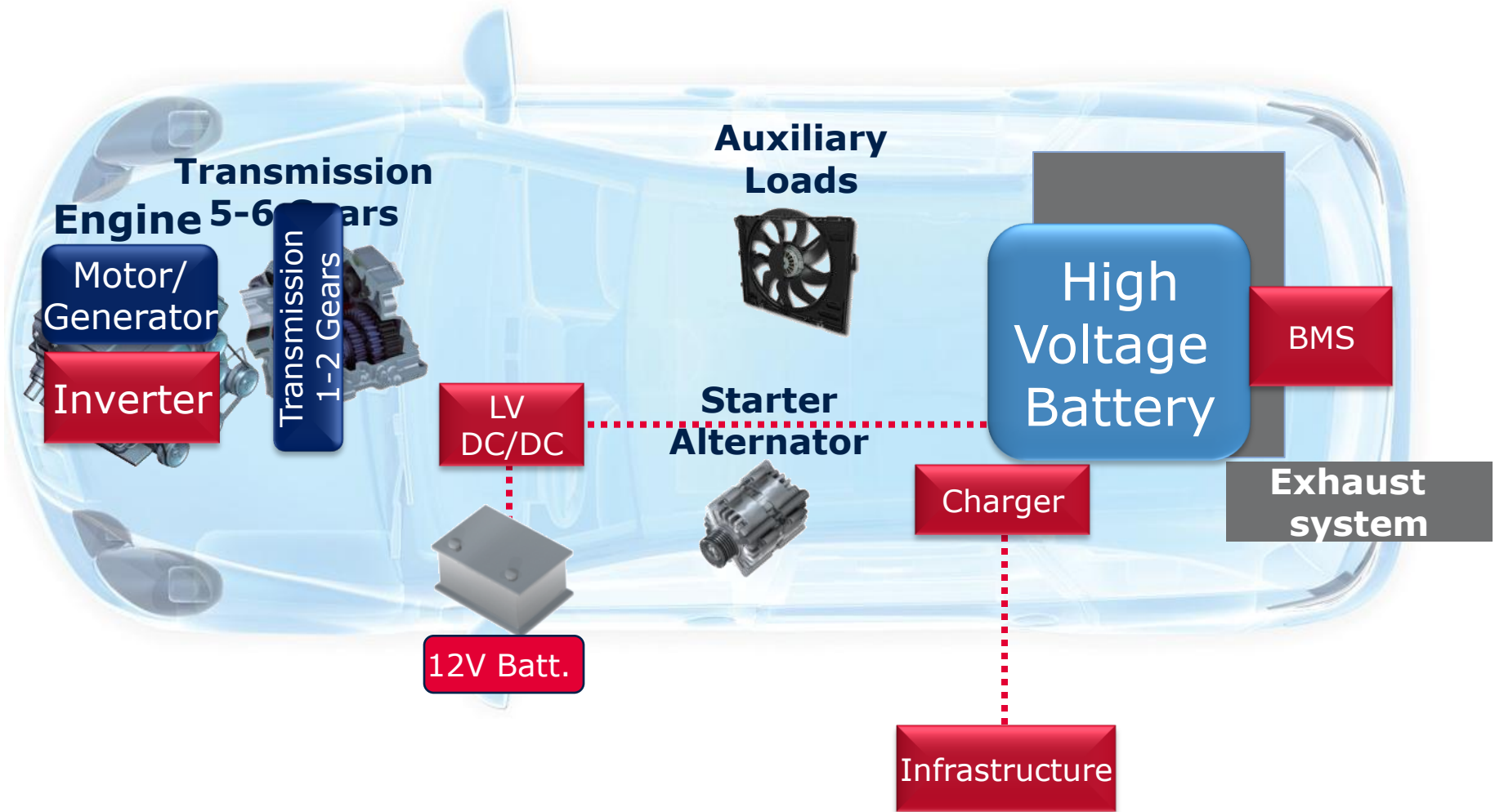
Energy consumption



Power Semiconductors



E-Mobility: A Total New Vehicle Architecture



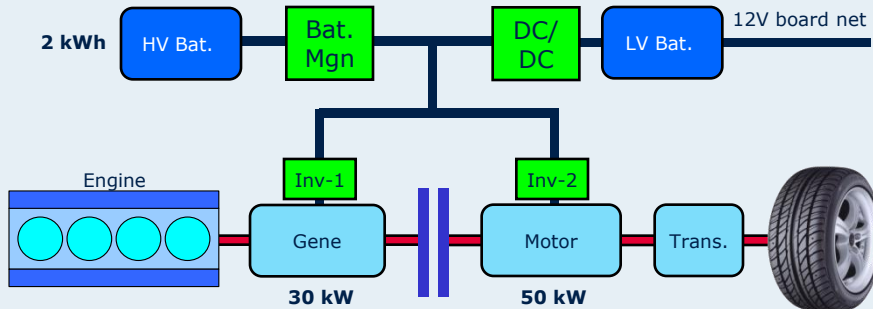
The vehicle electrification: a wide range of architectures

μ Hybrid

Parallel Hybrid

Serial Hybrid

Serial - Parallel Hybrid



Functions

- Start - Stop
- Regenerative braking
- Torque boost
- Low / part speed electric drive

Challenges

Challenges

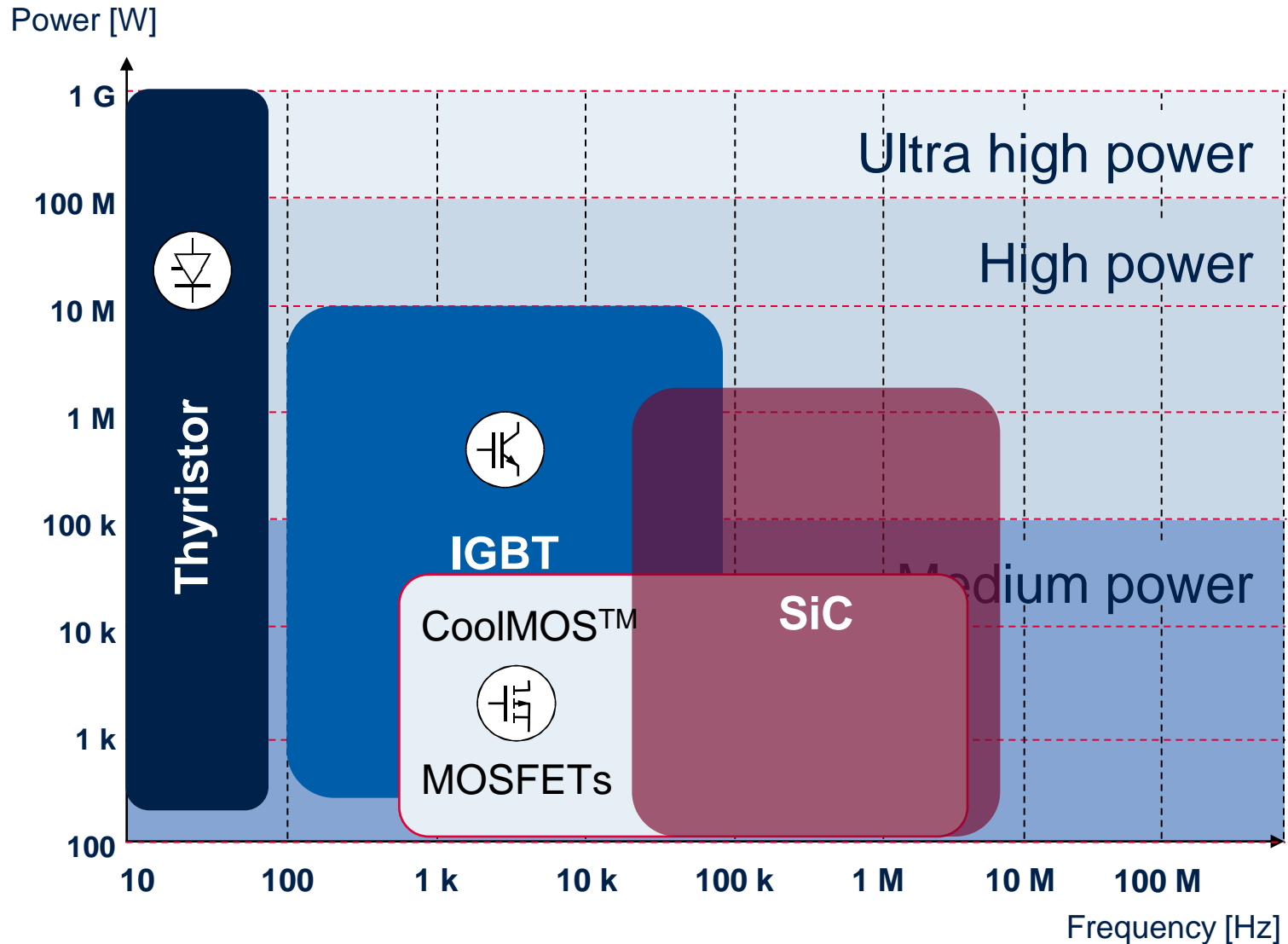
- Engine temperature control
- Emissions at Start & Stop
- Control of transient
- Safety critical X-by-wire
- Vehicle stability -> ESP
- High voltage
- Need of cabin heating
- Need of cabin cooling
- ...

Outline

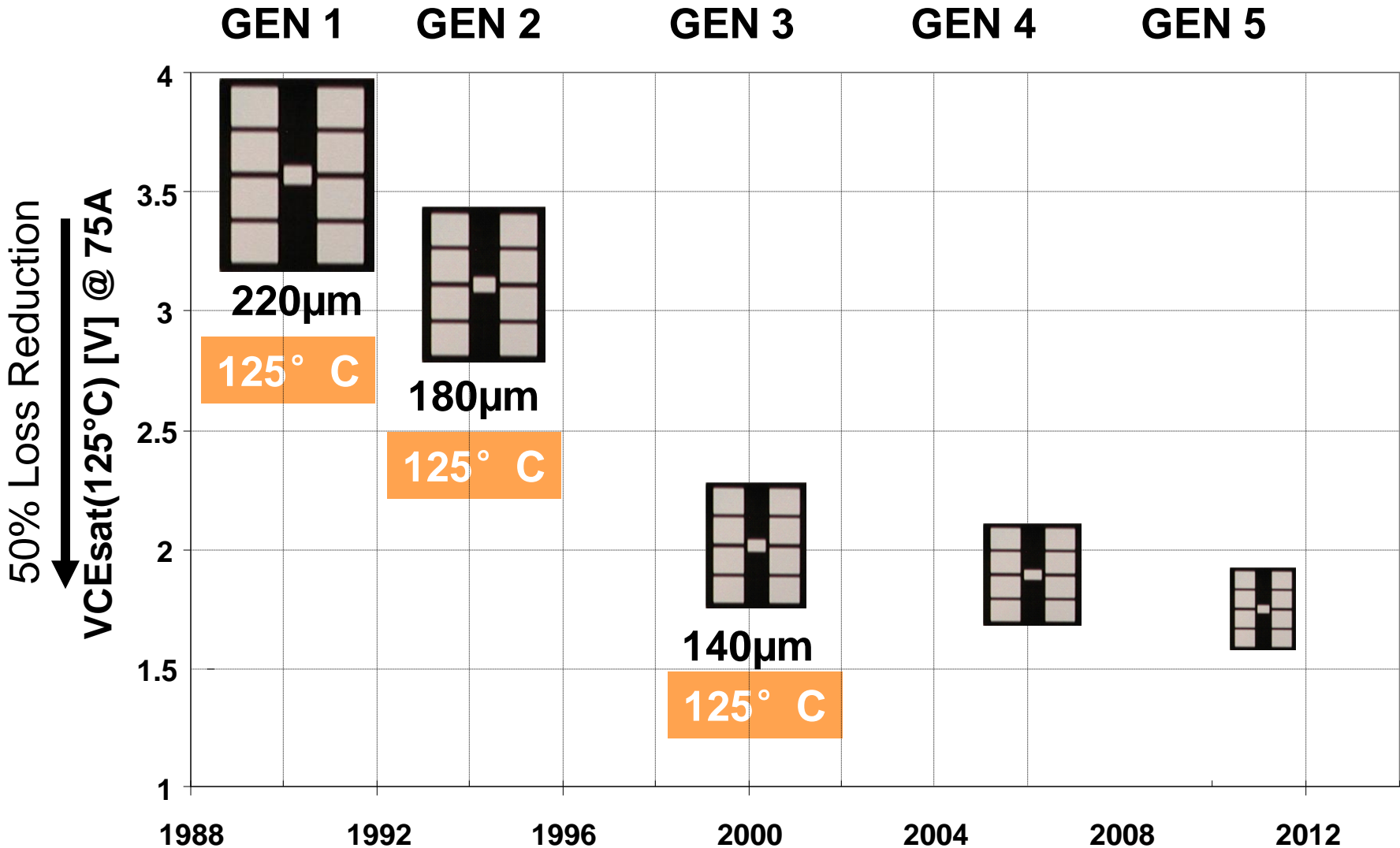
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- **General Development Trends of Power Devices**
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Power Semiconductors - Overview

Main characteristics: Power vs Frequency



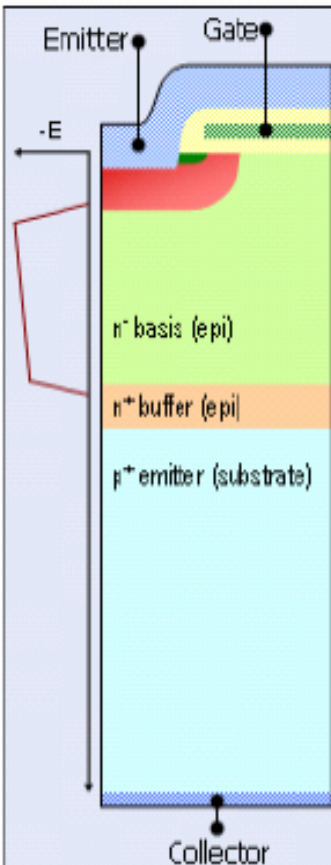
Efficiency and Increased Power Density ! Leads to Reduction in Losses, Increased Temperature



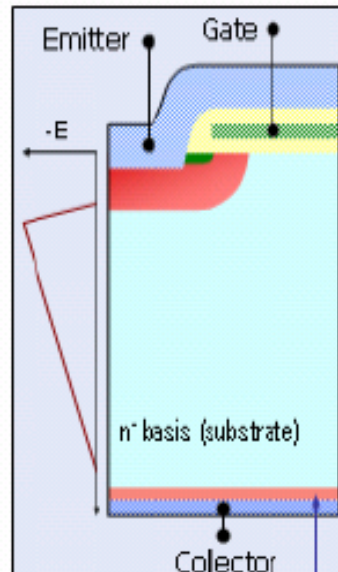
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Features > IGBT Chip Technologies

Punch Through



**IGBT1/2
Non Punch Through**



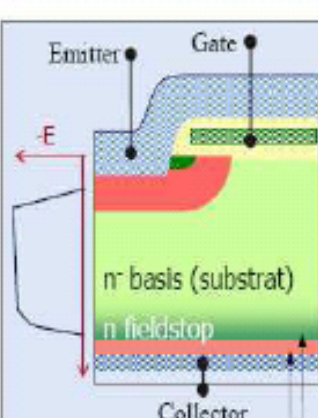
Advantage

- Implanted back-emitter better adjustable

Performance

- Lower switching losses
- Higher switching robustness

**IGBT2
Field-Stop**



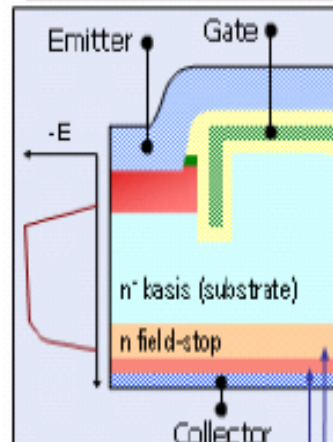
Advantage

- Implanted Back-Emitter
- Implanted Fieldstop enables thinner base region

Performance

- Lower V_{CEsat}
- Lower Switching Losses
- Robustness like NPT

**IGBT3
Trench + Field-Stop**



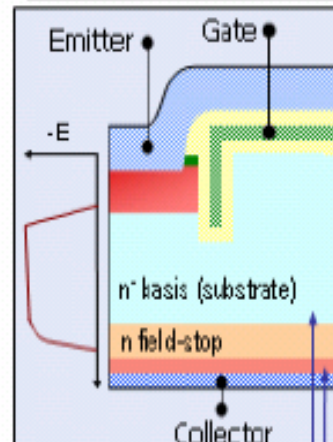
Advantage

- Implanted back-emitter
- Implanted field-stop enables thinner base region

Performance

- Lower V_{CEsat}
- Lower switching losses
- Robustness like IGBT2

**IGBT4
Trench + Field-Stop**



Advantage

- Optimized R_{Modulation}
- Adjusted Backside

Performance

- Lower switching losses
- Increased softness
- Robustness like IGBT3

Discontinued

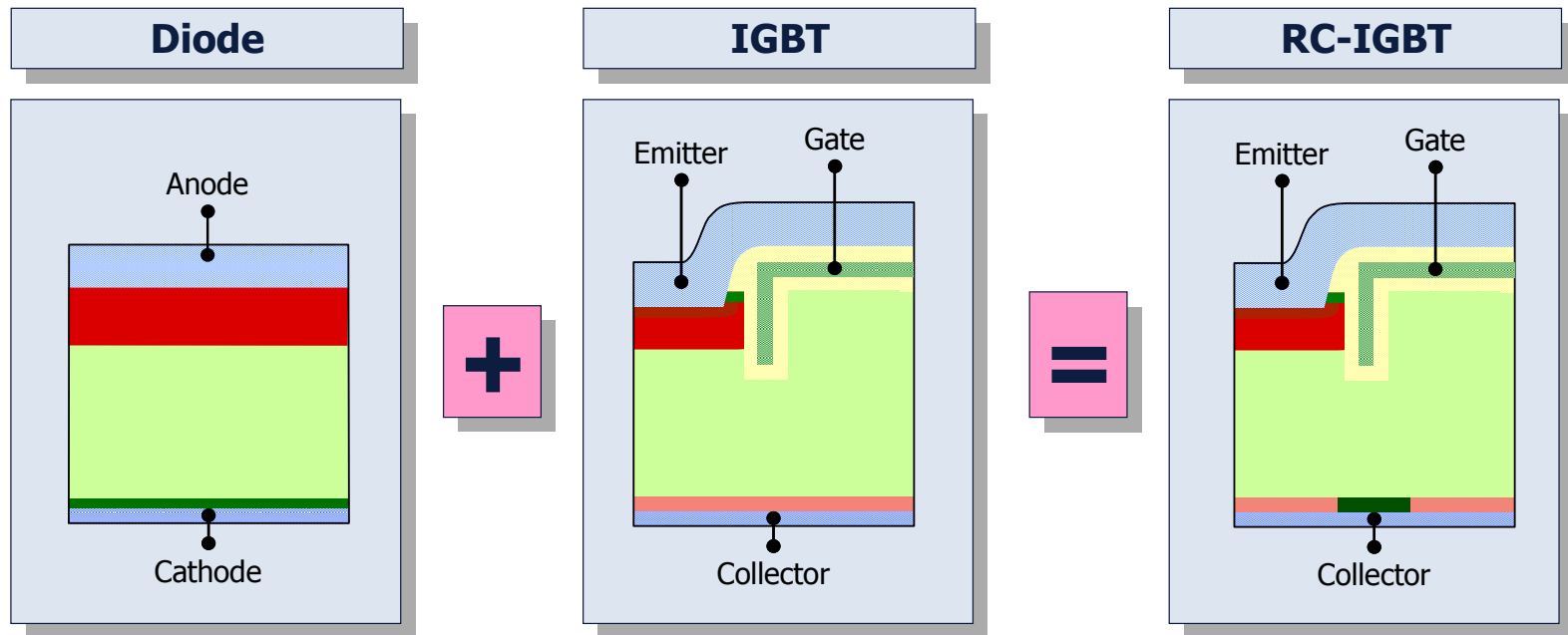
In use

In use

In use

Latest

NEW INNOVATION – Reverse Conducting Technology for Drives

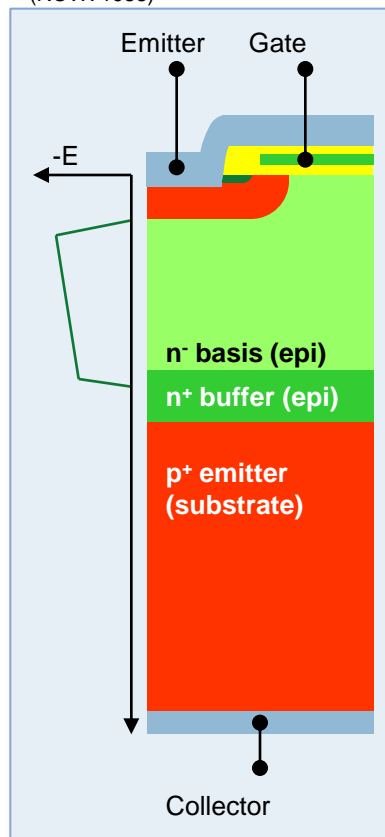


- **RC-D:** Infineon now offers the free wheeling diode monolithically integrated into the TRENCHSTOP IGBT-die for hard switching applications (**R**everse **C**onducting for **D**rives)
- Same DC current rating of diode and IGBT
- This leads to current classes [$<15\text{A}$] being available in new package classes.

IGBT Technology selection

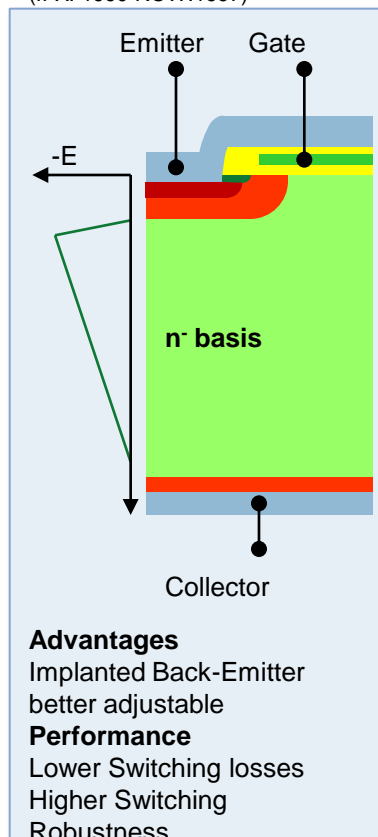
Punch Through

(ROW: 1988)



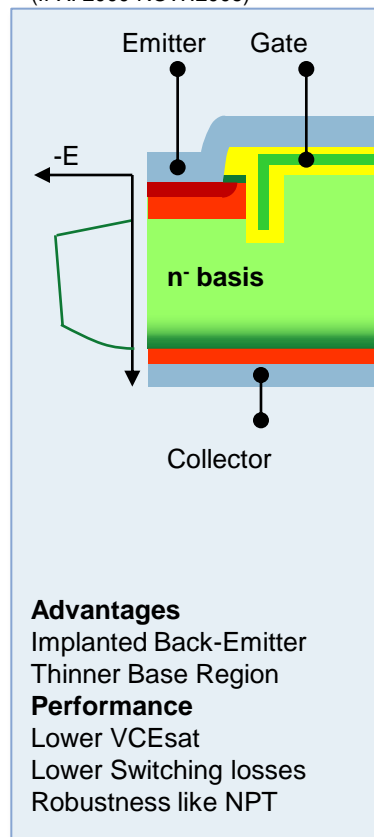
Non Punch Through

(IFX: 1990 ROW:1997)



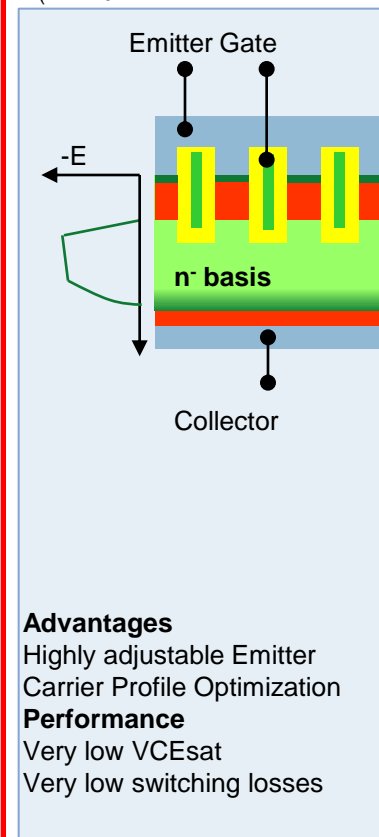
TRENCHSTOP™

(IFX: 2000 ROW:2006)



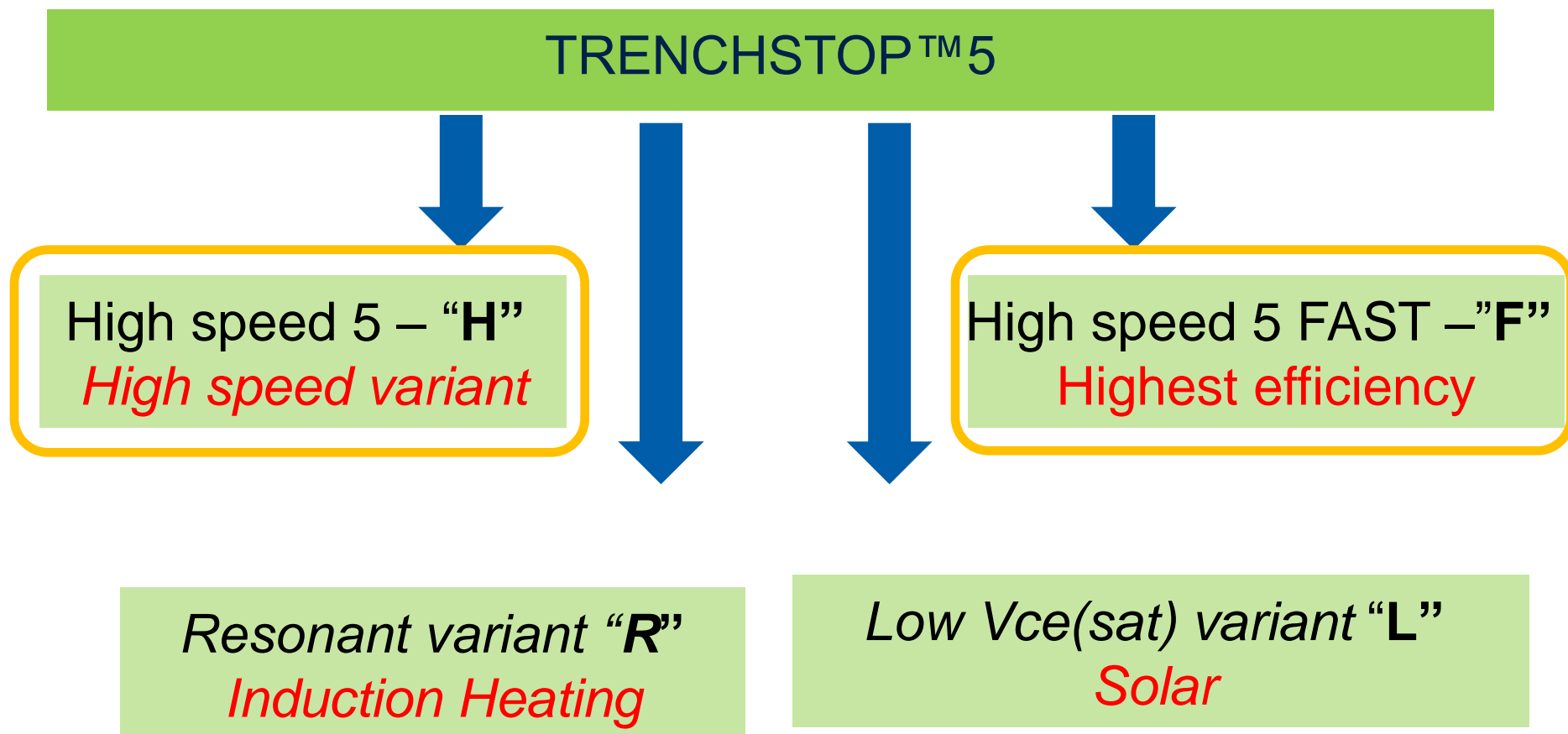
TRENCHSTOP™ 5

(IFX: 2012)

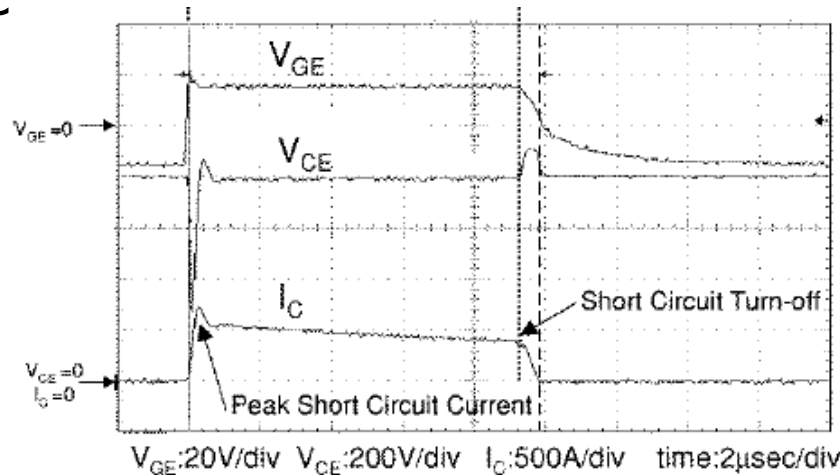
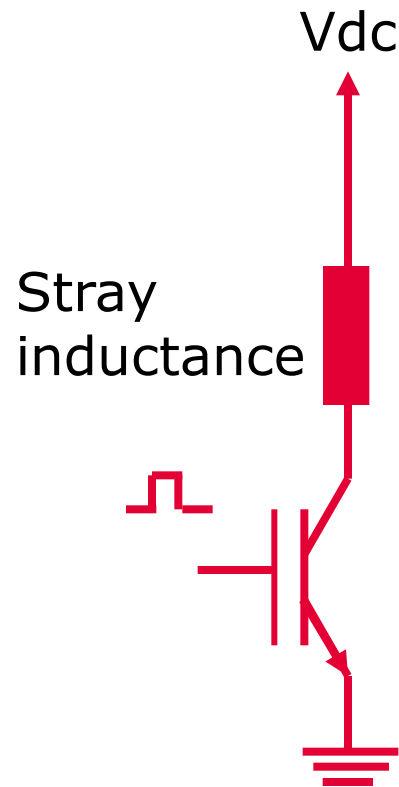


**High
Speed 5**

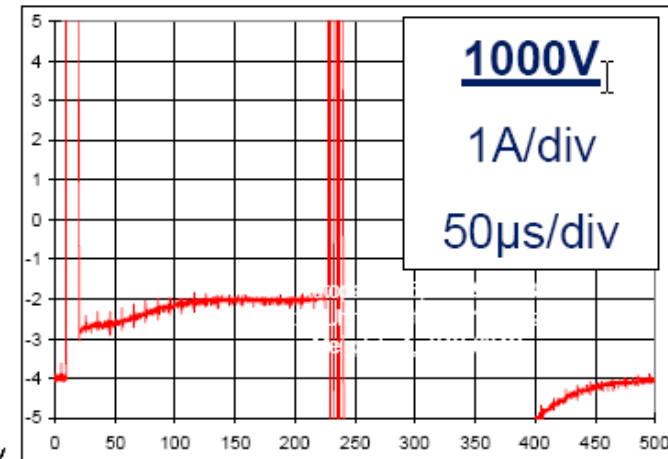
The TRENCHSTOP™5 Family Structure



Short circuit operation



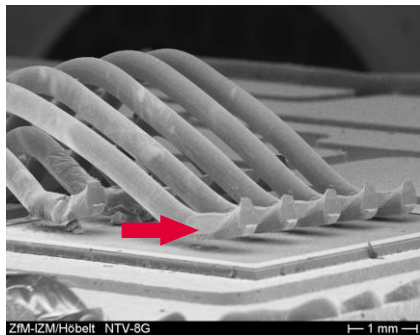
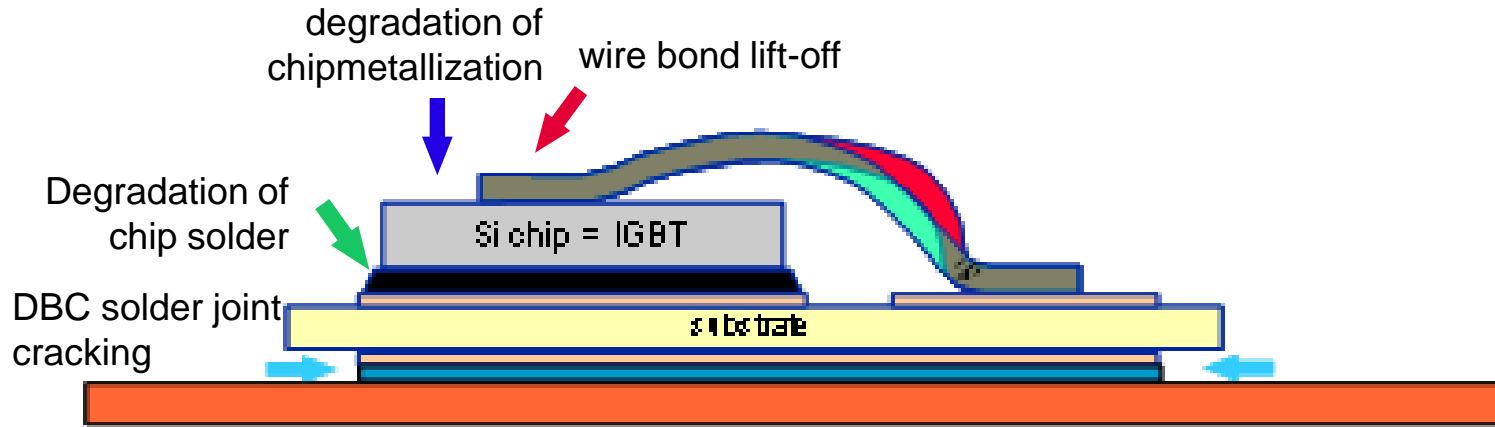
Destruction after the sc pulse



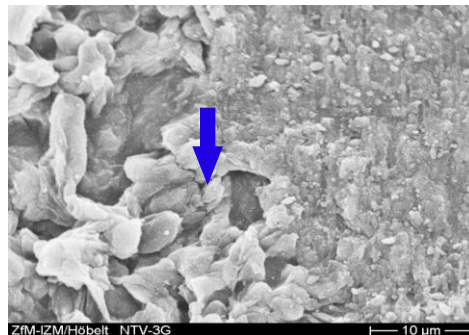
- Especially thin (600V .. 1200V) IGBTs are failing in this mode if the allowed short circuit time is exceeded
- Thinner silicon / high channel width
 - Reduced power losses
 - Reduced short circuit capability

Source: ISPSD 2010

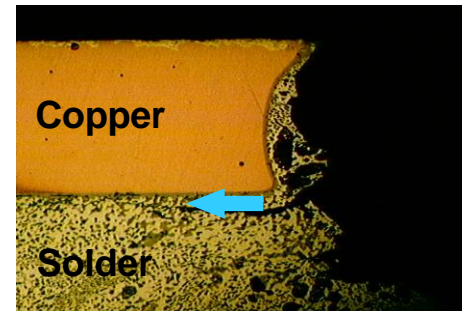
Reliability: modules failure mechanisms



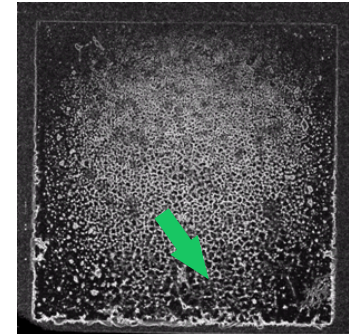
wire bond lift-off



degradation of chipmetallization



solder joint cracking

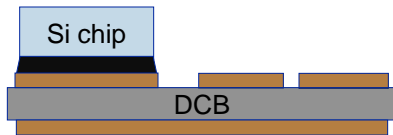


Degradation of chip solder

Future power module with .XT technology

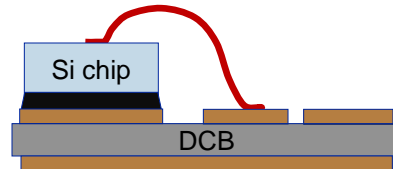
Standard Technology

Chip-to-substrate joint



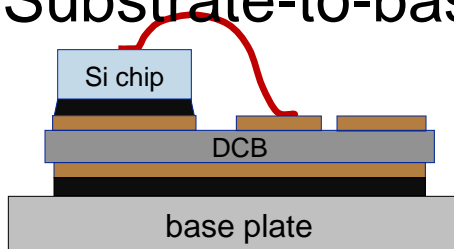
Soft soldering with SnAg paste

Front side interconnect



Al wedge bonding

Substrate-to-base plate joint



Soft soldering with SnAg pre form

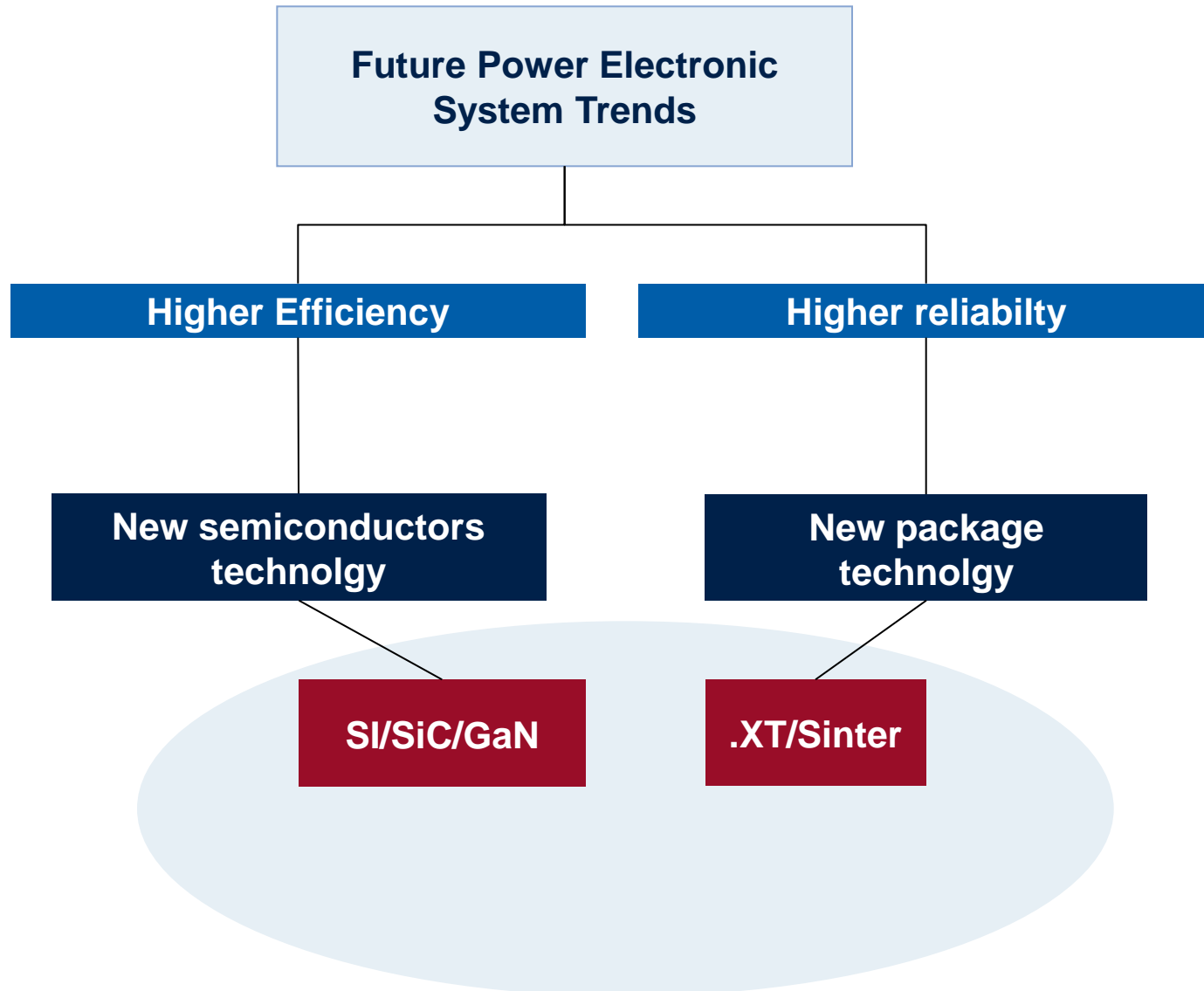


Diffusion soldering

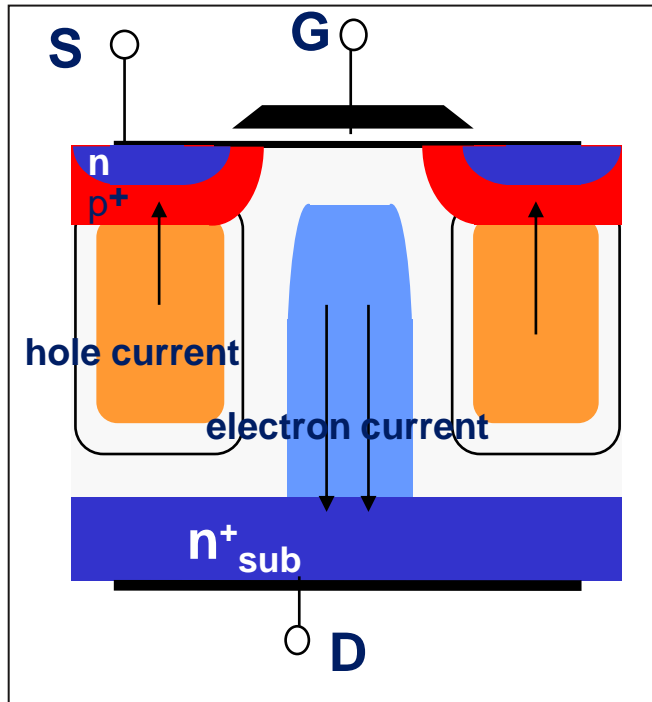
Cu wedge bonding

High reliability system soldering

Development Trends for High Reliable Systems

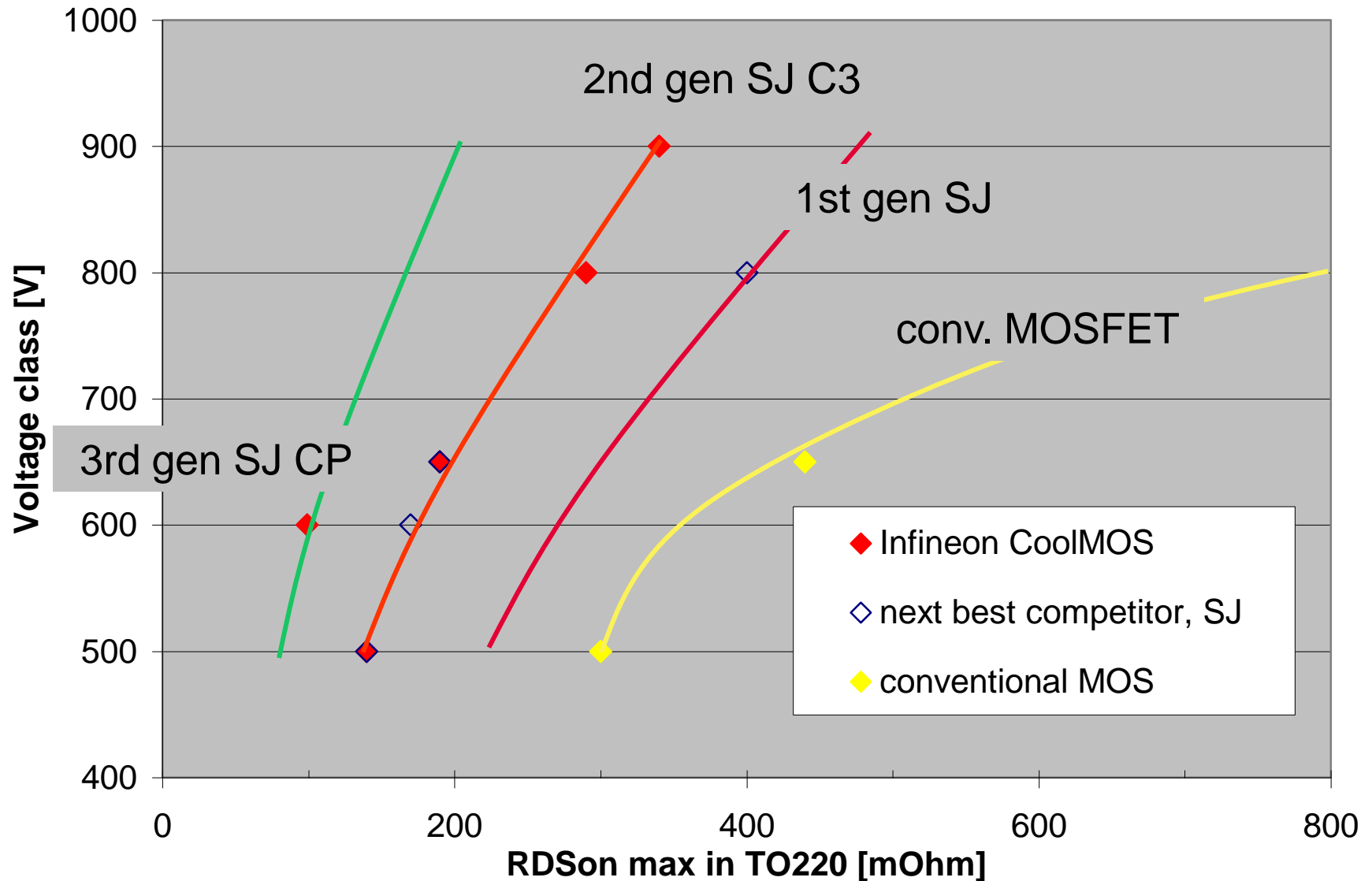


Where does the non-linearity in C_{ds} and C_{gd} come from?



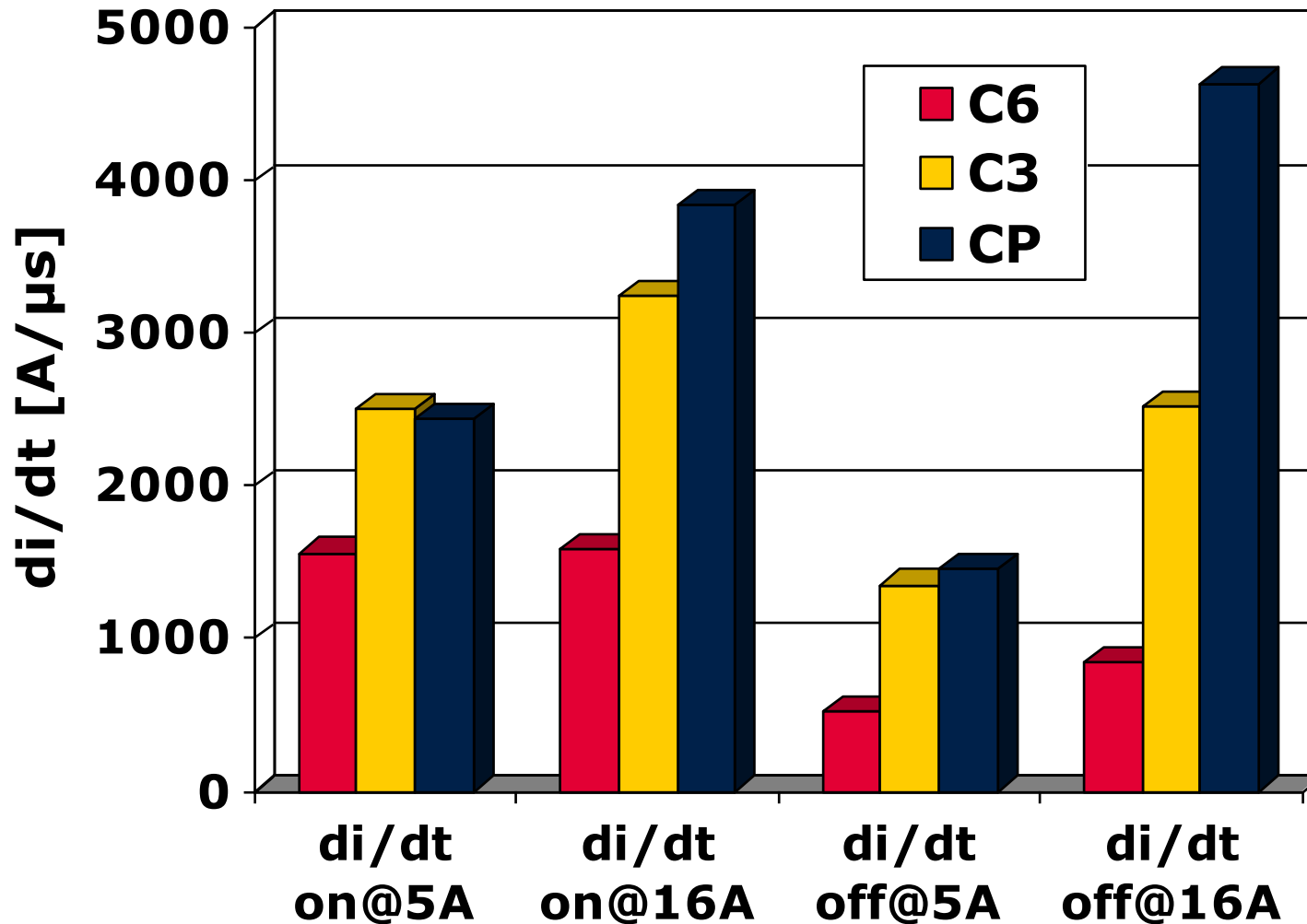
- Fast expansion of space charge region (SCR) from large area lateral pn-junction: high drain-source area at low voltage, strong decrease in area and increase in SCR width as a function of voltage
- Full depletion of active area at around 1/10th of nominal breakdown voltage
- High voltage limit of output capacitance given by width of SCR and active area of chip
- High voltage limit of reverse capacitance given by width of SCR and area overlap gate-to-drain

Infineon is contributing to efficiency targets from the power semiconductor side with CoolMOS™ ...

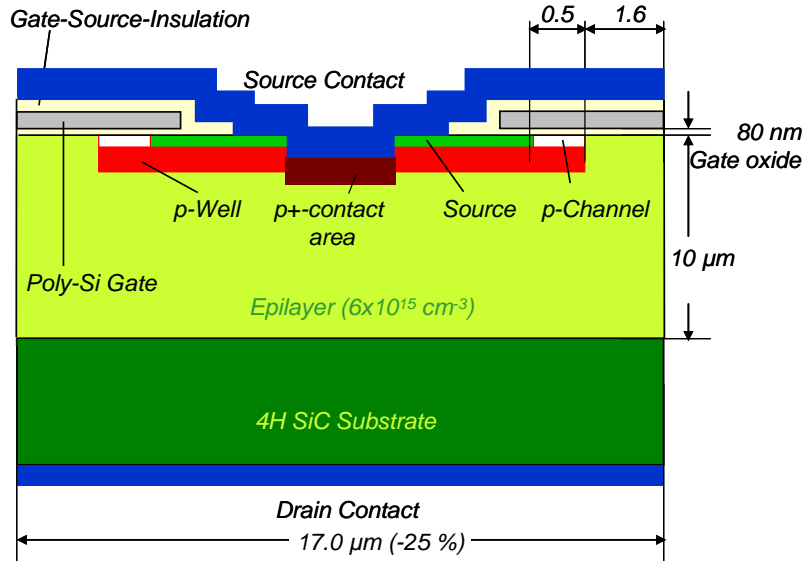


Comparison di/dt of CoolMOS C6 vs C3 and CP

190 / 199 mOhm types, R_g 3.3 Ohm, T_j=125° C



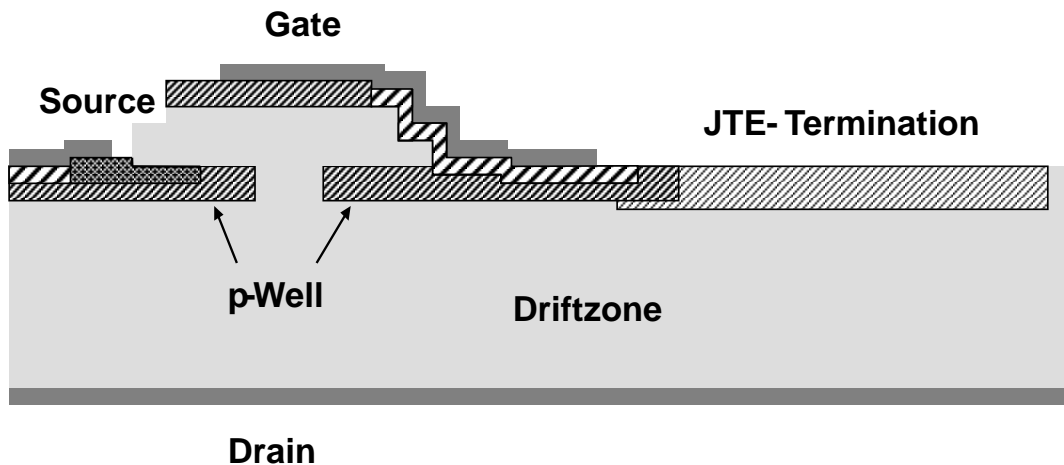
Choice of Device Concept: SiC MOSFET vs SiC JFET



Pro: normally-off

Con: channel mobility

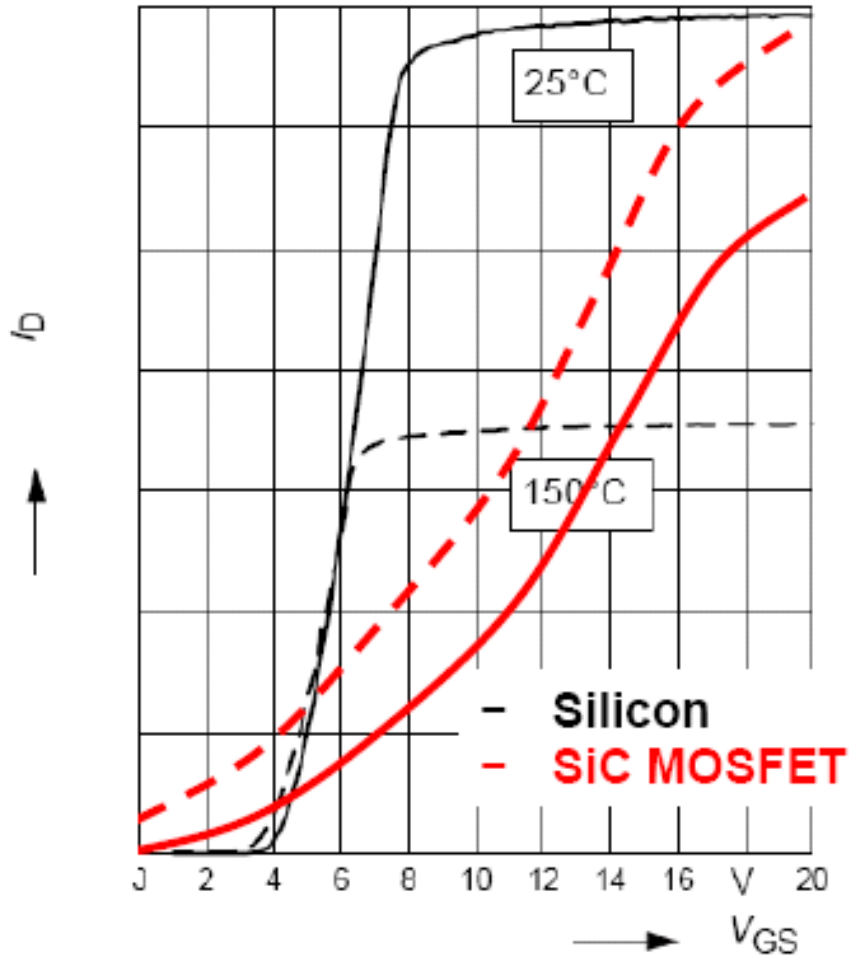
Oxide interface stability



Pro: Reliability
Performance

Con: normally-on

Channel mobility and threshold issue

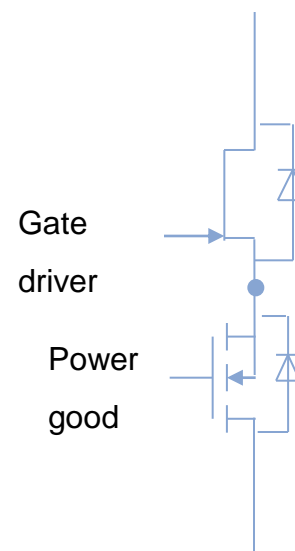
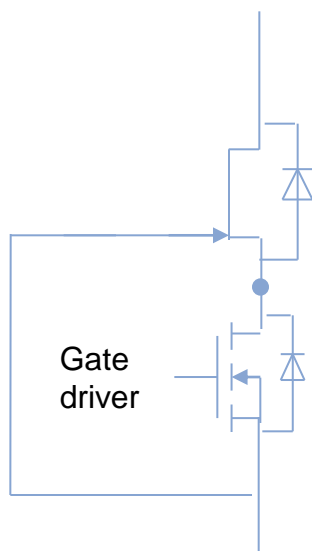


SiC MOSFET:

- Weak subthreshold characteristic
- High Millerplateau level, low g_{fs}
- Strong gate drivers required

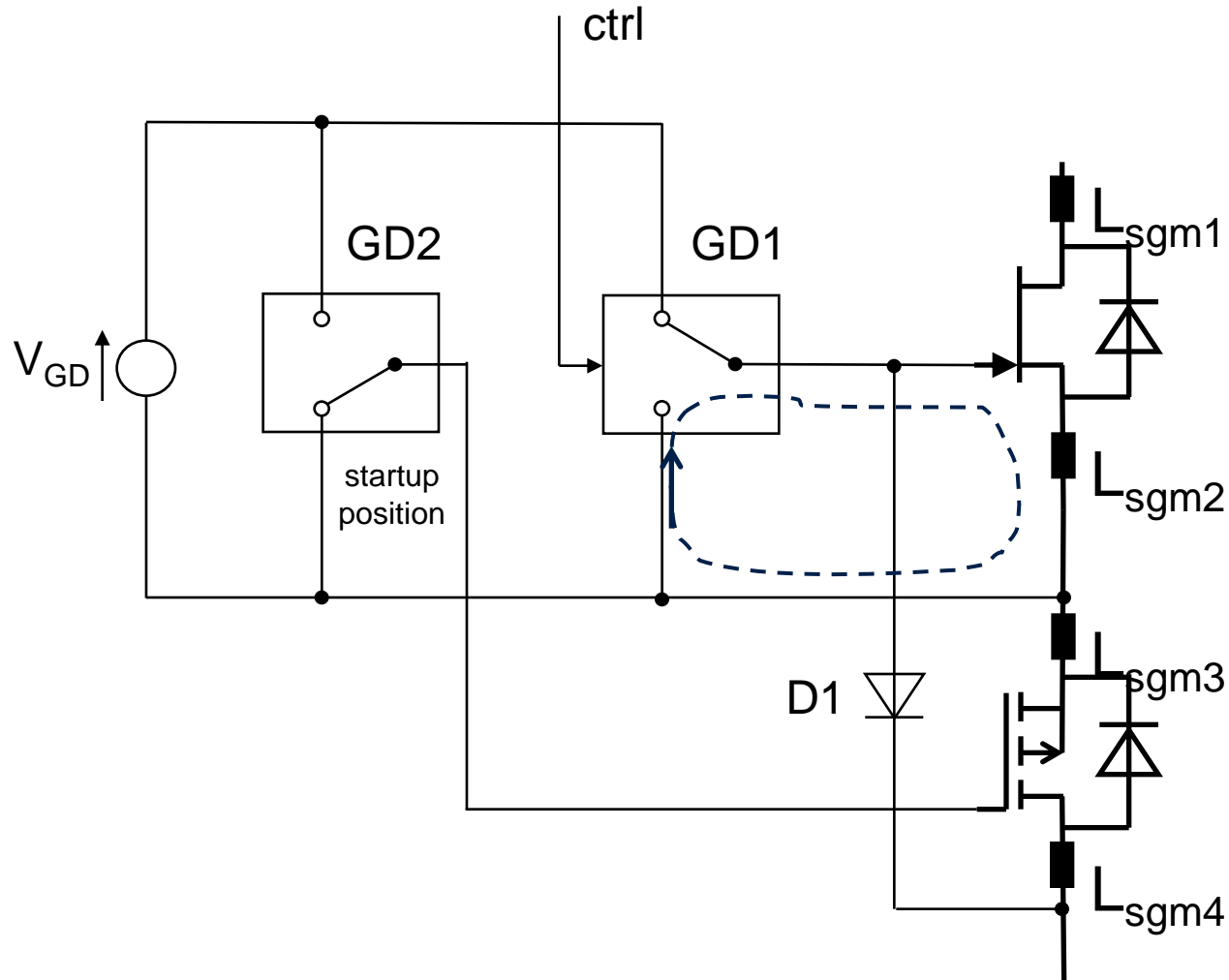
Challenge normally-on: Cascode concepts

	Cascode	Cascode light
Advantage	Normally off	best efficiency
	3 terminal device	direct control of JFET
Disadvantage	no feedback from JFET to Gate of LV MOS	normally on
	High capacitive charge from LV MOS	negative drive voltage required
	Injection of body diode Qrr in reverse operation	LV MOS still needed as safety valve



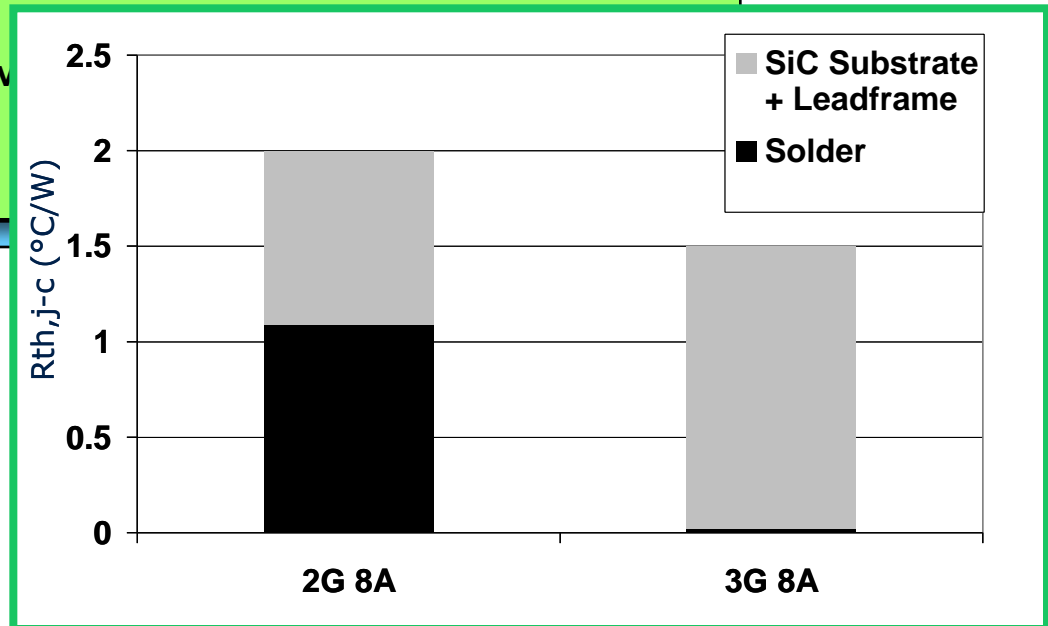
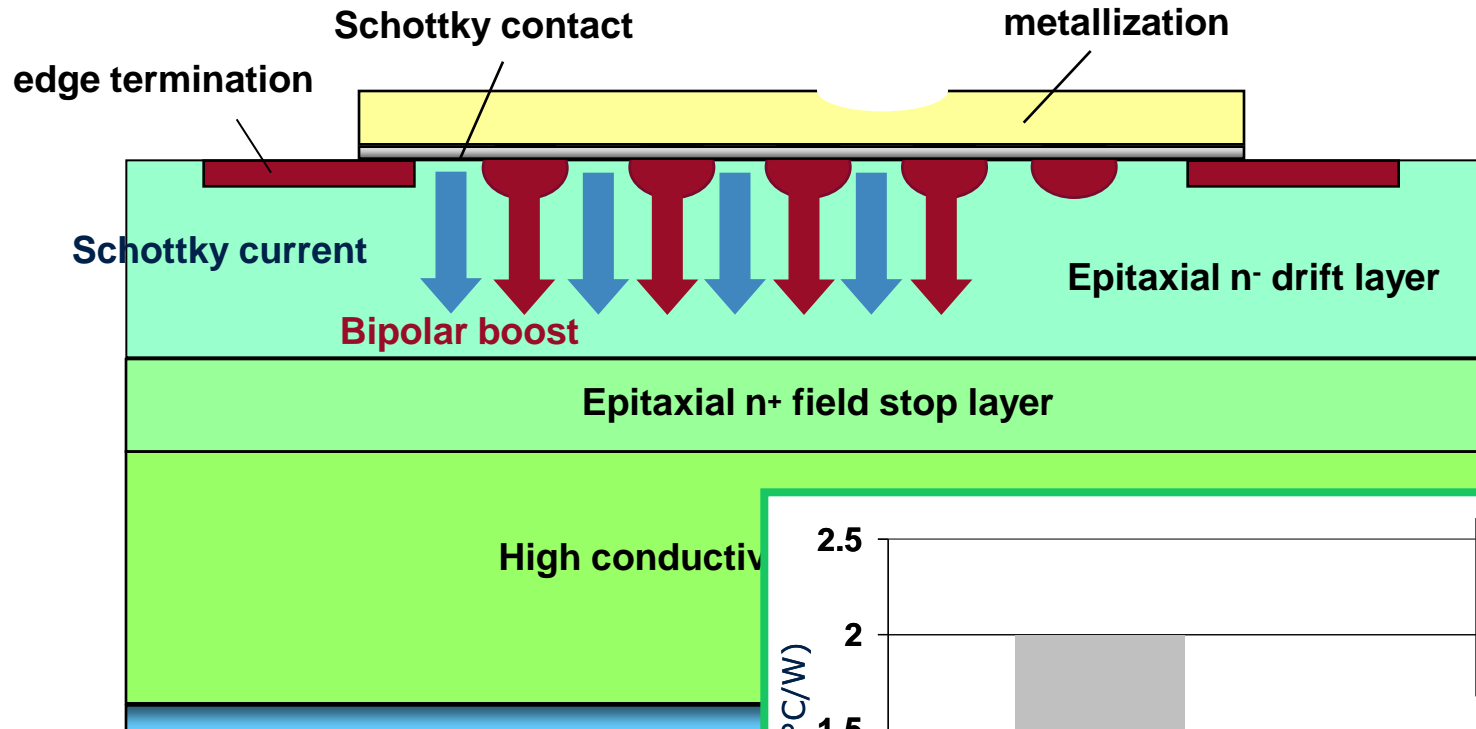
Direct driven schematic for SiC JFET

p-channel based solution



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The p-islands make the difference for the 2nd generation, substantially reduced solder resistivity for the 3rd gen!

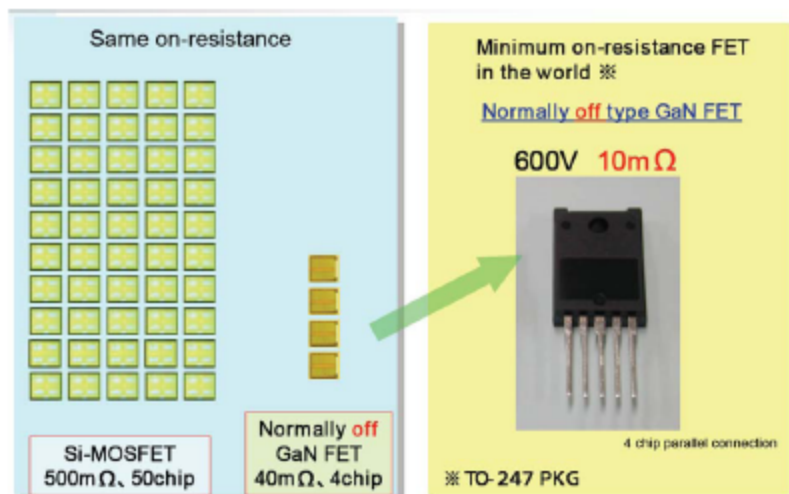


Comparison of Si & GaN devices

GaN vs. Si Switching Transistor Benchmarking

		GaN transistor	Si MOSFET
conduction losses (600 V)	$R_{DSon} \times A$	$0.001 \Omega\text{cm}^2$	$0.01 \Omega\text{cm}^2$
switching losses (200 V)	$R_{DSon} \times Q_G$	200 pVs	2000 pVs
temperature dependence	$R_{DSon}(125^\circ\text{C}) / R_{DSon}(25^\circ\text{C})$	1.5	2.2
maximum junction temperature	T_{Jmax}	$\sim 300^\circ\text{C}$	175°C

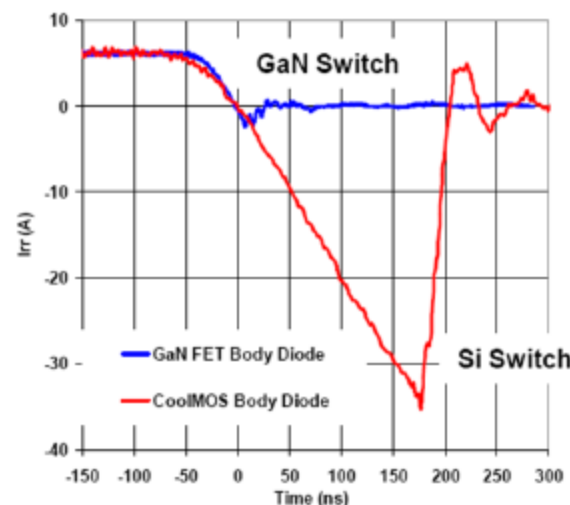
→ reduced chip size



Sanken, ISPDS '09

Source: Leibniz Insti.

→ reduced reverse recovery current



IR, APEC '10

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Fast Switching Power Transistor in Application

